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**Zn$_{1-x}$Fe$_x$O films: from transparent Fe-diluted ZnO wurtzite to magnetic Zn-diluted Fe$_3$O$_4$ spinel**

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**Abstract**

The different phases formed in Zn$_{1-x}$Fe$_x$O thin films where $x$ varies from 0 to 1, as well as their structural characteristics and physical properties, have been investigated. In particular, the interrelationships between the iron concentration, the oxygen composition and the microstructure of the films have been determined. The Zn$_{1-x}$Fe$_x$O films were grown on c-cut sapphire substrates by pulsed-laser deposition. For $0 < x < 0.35$, epitaxial films with a wurtzite (ZnO like) structure were obtained, while for $0.65 < x < 1$, spinel (Fe$_3$O$_4$ like) epitaxial films were observed. In the intermediate region ($0.35 < x < 0.65$) the phase separation of the Zn$_{1-x}$Fe$_x$O films leads to the formation of both wurtzite and spinel phases. Whatever is the $x$ value, the films display well-defined in-plane epitaxial relationships between the wurtzite (or spinel) phase and the substrate. The optical, electrical and magnetic properties of the Zn$_{1-x}$Fe$_x$O films are discussed in relation with their structural characteristics.

**Keywords:** Fe-doped ZnO films, zinc ferrite spinel, phase separation, oxygen deficiency
Introduction

Following theoretical calculations [1], transition metal doped ZnO was predicted as a promising diluted magnetic semiconductor with potential applications in spintronics. As a result, a lot of works has been devoted to the study of the growth and properties of ZnO thin films doped with various elements, magnetic or not [2,3]. However, the origin of the ferromagnetism in such systems was claimed either an intrinsic property of doped ZnO, or due to the presence of a secondary metallic phase [4,5]. Moreover, observation of room temperature (RT) ferromagnetism in undoped ZnO films revealed that the transition metal may not play an essential role in introducing magnetism in ZnO [6]. In the case of Fe-doped ZnO [7,8], the results are controversial and confusing, with papers reporting intrinsic ferromagnetism at RT or not, while others show the co-existence of paramagnetic, antiferromagnetism and ferromagnetism contributions [9]. In addition, the existence or not of Fe clusters has not been clearly established, except for a specific growth method, i.e. ion implantation followed by thermal annealing [5,10].

To clarify the situation in the Fe-doped ZnO system, we have studied the phase diagram of Zn$_{1-x}$Fe$_x$O films (0 < x < 1), by determining the nature of the phases present in the films and their physical properties. The Zn$_{1-x}$Fe$_x$O films were grown by pulsed-laser deposition (PLD) which allows a control of the oxygen incorporation in the films [11], i.e. on the oxygen composition. The influence of the cationic ratio x = Fe / (Zn + Fe) on the structural characteristics have been determined, and the specific effects of the oxygen stoichiometry on the phase formation have been highlighted. The extreme values of x correspond to oxide materials presenting very different properties. The x = 0 value corresponds to the ZnO wide band gap oxide, a transparent conducting oxide (TCO), while x = 1 corresponds to the magnetite Fe$_3$O$_4$, a ferromagnetic material with a high Curie temperature (858 K) presenting a half metallic behaviour. The optical, electrical and magnetic properties of the Zn$_{1-x}$Fe$_x$O films were studied in view to establish close correlations between the composition, structure and microstructure characteristics of the films with their physical properties.

Experimental

The zinc-iron oxide films were grown on c-cut sapphire by PLD, using a frequency quadrupled Nd :YAG laser (λ = 266 nm) delivering pulses (10 ns, 100 mJ/cm$^2$) irradiating the target [12]. The Zn-Fe-oxide ceramic targets were prepared by mixing powders of the precursor ZnO and Fe$_2$O$_3$ oxides to obtain the desired Zn/Fe proportion, followed by a sintering treatment at 1000°C. Film growth was carried out at 500°C under controlled pressure, between residual vacuum (5x10$^{-7}$ mbar) up to 10$^{-2}$ mbar oxygen pressure. After the growth the films were cooled down to room temperature (RT) at the oxygen pressure used during film deposition.

The film thickness and chemical composition were quantitatively determined by Rutherford backscattering spectrometry (RBS) using a 2 MeV $^4$He ion beam. The MeV ion backscattering analysis provides the ability to distinguish the atomic masses of elements and their in-depth distribution as a function the energy of the backscattered ions. The concentration profile of the various elements can be obtained from the simulation of the RBS
spectra by use of the RUMP program. A typical example for a Zn$_{1-x}$Fe$_x$O film in the high x range may be found in reference [13]. RBS measurements lead to 1% accuracy on the Zn and Fe concentrations. Differently, owing to the low RBS yield on light elements, the oxygen content is only obtained with a 4% precision. The nature of the crystalline phases present in the films was studied by X-ray diffraction (XRD) using an X’Pert Panalytical 4 circles diffractometer with Cu K$_\alpha$ radiation. The film texture and epitaxial relationships with the substrates were also investigated.

The optical transmittance of the films was measured with a spectrophotometer Cary 5000 in the 190-3200 nm wavelength range. The electrical properties (resistivity as a function of temperature from liquid helium up to 300 K) were obtained by the classical four probe method. The nature, concentration and mobility of charges were determined with a MMR Hall measurement system (in the van der Pauw geometry) at RT and under a magnetic field of 0.3 T. The magnetic properties of the films were measured by means of a Vibratometer Sample Magnetometer (VSM).

Results

Phase identification

The RBS measurements show that dense and smooth Zn$_{1-x}$Fe$_x$O films in the 50 to 200 nm thickness range are obtained whatever be the precise x value or the growth conditions used in this work. The iron atoms are uniformly distributed in the film, without noticeable segregation at the film/substrate interface or at the surface. The RBS analysis also shows that the films grown at the residual pressure (5×10$^{-7}$ mbar) present for x ≤ 0.05 a noticeable oxygen deficiency, i.e. around 10% of oxygen atoms are missing with respect to the “parent” ZnO phase, the film composition being Zn$_{1-x}$Fe$_x$O$_{1-\delta}$ where $\delta \approx 0.1$. On the contrary, for 0.25 ≤ x < 0.5, the film composition is close to a stoichiometric compound Zn$_{1-x}$Fe$_x$O$_{1-\delta}$, where −0.05 ≤ $\delta$ ≤ 0.05. Last, for x ≥ 0.5, the chemical composition is Zn$_{1-x}$Fe$_x$O$_{1-\delta}$ where 0.25 ≤ $\delta$ ≤ 0.35. In this latter case, the “parent” phase is Fe$_3$O$_4$ and the film chemical composition should be viewed as deriving from the spinel Zn$_{1-x}$Fe$_x$O$_{4-\beta}$ phase, where $y = 3-3x$ and $\beta = 1 - 3 \delta$ accounts for the oxygen deficiency. For sake of simplicity, the two types of phases (wurtzite and spinel) will be referred to in the rest of the paper using the generic term Zn$_{1-x}$Fe$_x$O with 0 < x < 1.

Fig. 1 represents 0-2θ XRD diagrams corresponding to Zn$_{1-x}$Fe$_x$O films (0 < x < 1) grown on sapphire substrates under residual pressure (5×10$^{-7}$ mbar), for 2θ values between 28 and 40°, i.e. in the angular range where the main diffraction peaks of the two oxide compounds (ZnO wurtzite and Fe$_3$O$_4$ spinel) are present as indicated in the figure. These 0-2θ diagrams are normalized to the film thickness, and the peak intensity can thus be directly compared, and used to evaluate the crystalline quality of the films.

Schematically three domains in composition can be defined:

- At low x values (0 ≤ x < 0.35), a sole peak is present corresponding to the 002 reflection of the hexagonal ZnO wurtzite structure, meaning that the Fe doped ZnO films present a (001) texture as it is observed for pure ZnO films grown in the same conditions. This peak is shifted towards decreasing 2θ values as x increases, indicating that the c lattice parameter of the wurtzite phase increases. Moreover, the overall peak area in the diagram largely decreases as x increases indicating that the amount of the amorphous fraction of the film increases with increasing Fe content.
For the highest Fe concentrations (x > 0.65), a single peak located at about 37° is observed. It corresponds to the 222 reflection of the cubic zinc ferrite \((Zn_yFe_{3−y}O_4)\) spinel structure, and both its position and its width do not widely change with the x value. This is related to the fact that the lattice parameter value of the cubic zinc ferrite \(Zn_yFe_{3−y}O_4\) shows a limited variation range between 8.395 Å (y = 0) and 8.43 Å (y = 1). At this stage, the discrimination between the different possible spinel phases (\(Zn_yFe_{3−y}O_4\) or both \(Fe_3O_4\), \(ZnFe_{2}O_4\)) is not possible.

In the intermediate region (0.35 < x < 0.65), the formation of both the wurtzite phase and a second oxide phase occurs via some kind of “phase separation” in the \(Zn_{1−x}Fe_xO\) films. Indeed, for x = 0.35 a small peak appears around 36°. Its position could correspond to the 111 reflection of the cubic \(FeO\) structure \((a = 0.43\,\text{nm})\) indicating the presence of such \(FeO\) clusters in the \(ZnO\) wurtzite matrix. It has to be noticed that owing to the face centered cubic \(FeO\) structure, the 111 reflection should not be observed. However, the presence of defects related to oxygen deficiency and \(Zn\) incorporation in \(FeO\), would make possible the presence of the 111 peak in the θ-2θ diagram. Anyway, this peak disappears with increasing x value (x = 0.5), while a well-defined 222 spinel peak is present at 36.9°. At this step both wurtzite and spinel phases are textured on the c-cut sapphire substrate.

The c-axis parameter of the hexagonal wurtzite phase and the a-axis parameter of the cubic spinel phase were determined from the 002 \(ZnO\) and 222 spinel diffraction peaks on the θ-2θ diagrams, respectively. The a-axis parameter of the wurtzite phase was determined through the position of the 011 or 103 diffraction peaks. Fig. 2 summarizes these measurements and shows that the wurtzite c-axis is an increasing function of the Fe dopant concentration up to x = 0.5 for films grown under \(5 \times 10^{-7}\) mbar. On the other hand the a-axis parameter does not show such large variations. These results evidence an expansion of the \(ZnO\) lattice along the c-axis as the Fe dopant concentration increases which indicates that an increasing amount of Fe atoms is incorporated in the \(ZnO\) network. For x = 0.65, both wurtzite and spinel phases are present and the c-axis decreases, reaching a value similar to that observed for x = 0.05, indicating that the main fraction of Fe atoms is in the spinel phase.

Despite the incorporation of Fe in the wurtzite \(ZnO\) matrix, and the large variation in the c-axis parameter, the epitaxial growth of \(Zn_{1−x}Fe_xO\) films on c-cut sapphire substrates was observed and investigated by poles figure measurements. Fig. 3 represents typical pole figures recorded for films grown in the wurtzite and spinel domains, respectively. For low x values (x = 0.25), i.e. wurtzite films, Fig. 3a shows the pole figure for the 011 \(ZnO\) reflection at θ = 36.25°, with 6 poles located at a declination angle \(Ψ = 61°\). The azimuthal position of these poles allows deducing the following epitaxial relationship with the c-cut sapphire substrate:

\[
Zn_{1−x}Fe_xO [100] // Al_2O_3 [210] \quad (I)
\]

This relationship corresponds to a 30° rotation of the hexagons of the (001) wurtzite plane with respect to the hexagons of the (001) \(Al_2O_3\) plane. This is the classical epitaxial relationship observed for pure \(ZnO\) films grown on c-cut sapphire substrate at 500°C [14]. In this situation, the hexagonal close-packed oxygen sub-lattices in both sapphire substrate and zinc oxide film have an identical in-plane orientation ensuring a continuity of the oxygen network through the film-substrate interface. For large value of Fe concentration (x = 0.85), the spinel zinc ferrite phase is formed and epitaxial films were also observed as it can be deduced from Fig. 3b which represents the pole figure recorded for the 220 spinel reflection at θ = 29.8°. Six poles are observed on this figure at \(Ψ = 35°\), i.e. the value expected for spinel crystallites with the (111) texture. The following in-plane epitaxial texture was deduced:

\[
Zn_yFe_{3−y}O_4 [10-1] // Al_2O_3 [210] \quad (II)
\]
This relationships also corresponds to a 30° rotation of the hexagons of the (111) spinel plane with respect to the hexagons of the c-cut sapphire substrate. In the intermediate domain (0.35 \( \leq x \leq 0.65 \)), although a large fraction of the films is amorphous, both wurtzite and spinel phases are present and both were found epitaxially grown on the c-cut sapphire substrates.

For \( 0 \leq x \leq 0.65 \), the wurtzite phase presents the epitaxial relationships of pure ZnO on c-cut sapphire substrate grown in the same conditions, i.e. the classical 30° rotation of the film hexagons with respect to the sapphire hexagons substrate [14]. This epitaxial growth explains the absence of large variations of the a-axis parameter of the wurtzite phase (while the c-axis parameter shows noticeable variations). Indeed, a well-defined in-plane epitaxial relationships exists which is explained in the frame of the domain matching epitaxy [15]. The a-axis of the Fe doped ZnO phase is fixed by this epitaxial relationship and does not widely change with increasing Fe concentration. On the contrary the c-axis is not fixed by the in-plane epitaxial relationships and this leads to the expansion of the Fe doped ZnO crystallites along the c-axis.

**Phase formation**

The oxygen pressure during the growth was found to play an important role on the phase separation in the Zn\(_{1-x}\)Fe\(_x\)O film. Fig. 4 compares the 0-20 XRD diagrams of Zn\(_{0.5}\)Fe\(_{0.5}\)O films grown at the residual pressure and \(10^{-2}\) mbar respectively. For the film grown at low pressure the 222 reflection of the zinc ferrite spinel phase is observed, while at high pressure (\(10^{-2}\) mbar), this peak is not present. Moreover the 002 wurtzite peak is more shifted towards the lowest 20 values at \(10^{-2}\) mbar than at residual pressure indicating a higher c-axis value and thus a higher concentration of Fe in the wurtzite phase. In the same way its intensity is lower than that at residual pressure meaning that the amorphous fraction of the film is higher at \(10^{-2}\) mbar. The films grown under \(10^{-2}\) mbar oxygen pressure also show that the c-axis is an increasing function of the Fe concentration up to \(x = 0.65\), from which the phase separation into wurtzite and spinel phases occurs (Fig. 2). All these points mean that the phase separation of Zn\(_{1-x}\)Fe\(_x\)O films into wurtzite and spinel phases is favored under low oxygen pressure growth, i.e. in conditions where oxygen deficient films are formed. This result is in agreement with previous results on the phase separation which occurs in oxygen deficient tin doped indium oxide which can lead, for a complete phase separation, to the formation of metallic clusters in a stoichiometric matrix [16-18]. It has to be noticed that diffraction peaks associated to Fe metal clusters were never observed in this work even for high Fe concentrations.

The appearance of a secondary phase (FeO and/or spinel) phase in the 0-20 XRD diagrams via the phase separation in Zn\(_{1-x}\)Fe\(_x\)O films, occurs for \(x \geq 0.35\) in residual pressure conditions. Such a concentration is largely higher than the solubility limit of Fe in ZnO which is in the 1.5% to 5% range following previous reports [19,20]. It has been shown in the case of nanoparticles assembly that the overall Fe solubility in ZnO drastically increases with the decreasing size of the ZnO nanoparticles. Indeed the overall solubility of Fe in nanograinized ZnO films (grain size 6-15 nm determined by XRD and TEM measurements) reaches about 20 at. % at 550°C [21]. The reason why would be the accumulation of Fe towards the external zone of the nanoparticles leading to the formation of Fe-enriched ZnO amorphous boundaries with thickness up to 1 nm [21]. The Fe rich amorphous boundaries are supposed to be at the origin of the secondary phase which appears at increasing Fe concentrations. Such a segregation of transition metal at the grain boundaries in Zn\(_{1-x}\)Mn\(_x\)O films has also been inferred from electron paramagnetic resonance and transmission electron microscopy analyses [22].
The comparison with the results reported here leads to the conclusion that a similar phenomenon occurs during the Zn$_{1-x}$Fe$_x$O film growth at 500°C under 5x10$^{-7}$ mbar. Actually, in addition to the shift of the ZnO-like 002 peak, a broadening of this peak is observed with the increase in Fe concentration (Fig. 1). The width of the 002 peak depends upon both the crystallite size (coherent domain) and microstrain in the film. To precisely determine the grain size, the Williamson-Hall plot should be used, but in the case of a textured (00l) ZnO films such an approach leads to inaccurate values. For comparison purpose, we have thus only used the Debye-Scherrer formulae to estimate the grain size of the ZnO crystallite in our films. This estimation through the Debye-Scherrer formulae leads to values ranging from 16 nm for x = 0.05 to 10 nm for x = 0.35, a variation similar to that reported in the case of granular films [21]. At the same time Fig. 1 shows that the intensity of the 002 peak largely decreases, indicating a decrease of the ZnO crystalline phase present in the films, i.e. amorphous regions are created with the increase in Fe concentration. The decrease in ZnO grain size and the decrease of the amount of crystalline ZnO can thus be explained by the formation of Fe rich amorphous grain boundaries (and later the formation of crystallized FeO-like grains).

Electrical Properties

Hall measurements indicate that n-type films are formed whatever the Fe concentration. In oxide films the oxygen stoichiometry plays an important role on the resistivity since oxygen vacancies usually act as electron donors. Depending upon the oxygen pressure during the PLD growth, the resistivity of the Zn$_{1-x}$Fe$_x$O films presents very large variations. In what follows we only present the results concerning the films grown at the residual pressure 5x10$^{-7}$ mbar. Fig. 5 shows the resistivity as a function of the Fe concentration. The density and mobility of the carriers deduced from the Hall measurements are given for 0 < x < 0.4 for which no magnetic phase is present, avoiding thus the existence of the anomalous Hall effect.

For 0 < x < 0.35, the resistivity $\rho$ drastically increases with Fe concentration. Indeed, while at x = 0.05, $\rho$ is close to the value measured on pure ZnO films grown under the same conditions (about 10$^2$ Ωcm), for x = 0.25 the $\rho$ value is 4 10$^9$ times higher. This large increase is due to a decrease of both the density and mobility of carriers as shown in Fig. 5, and it has to be related to the microstructural characteristics of these films. Actually with an increase in Fe concentration, the size of the ZnO crystallites decreases and Fe rich amorphous grain boundaries are formed. Scattering of the electrons in these grain boundaries are presumably very important and drastically reduce the carrier mobility. The decrease in the carrier density could be related to the presence of both Fe$^{3+}$ and Fe$^{2+}$ in the wurtzite phase [7, 23]. In fact, the carrier density in ZnO films is related to the presence of oxygen vacancies. The decrease of the carrier density means a neutralization of these oxygen vacancies and this can be obtained by the transformation of Fe$^{3+}$ cations into Fe$^{2+}$ cations. These changes lead to the annihilation of oxygen vacancies, and the increase in Fe concentration will thus drastically decrease the carrier density. It has to be noticed that the change from Fe$^{3+}$ to Fe$^{2+}$ would lead to modifications in the wurtzite lattice. In fact, the Fe$^{3+}$ ionic radii (0.64 Å) is lower than that of Zn$^{2+}$ (0.74Å), and thus does not lead to an expansion of the ZnO lattice. Differently, the presence of Fe$^{2+}$ (ionic radii equal to 0.76Å) will induce an expansion of the ZnO network. The increase in Fe$^{2+}$ amount in the ZnO network with increasing Fe concentration would, at least partly, explain the large expansion of the ZnO unit cell along the c-axis (see Fig. 1 and 2).
In the spinel domain (0.65 < x < 1), the carrier transport occurs in the zinc ferrite phase (which is the sole phase present in this domain) with a low resistivity $2 - 4 \times 10^2 \ \Omega \text{cm}$, which is similar to that measured in $\text{Zn}_x\text{Fe}_{3-x}\text{O}_{4-\delta}$ ($y = 0.5 - 0.9$) thin films grown under reducing conditions [13, 24].

A maximum of resistivity is observed for $x = 0.35$, i.e. just at the beginning of the phase separation in which FeO or/and spinel crystallites start to be formed. Then in the intermediate wurtzite and spinel domain (0.35 < x ≤ 0.65) the resistivity is a decreasing function of the Fe concentration. This resistivity variation in this domain is characteristic of the presence of both highly defective and resistive Fe doped ZnO nanograins, and crystalline spinel presenting a noticeable conductivity. The increase in the Fe concentration increases the amount of the spinel phase at the expense of the Fe doped ZnO, and as a result the overall resistivity decreases.

To draw more information on the carrier transport, the resistivity as a function of temperature ($\rho(T)$ curve) was measured, and Fig. 6 shows the main results. All the curves present a negative temperature coefficient of resistivity (TCR), i.e. an increase in resistivity for decreasing temperature, but this common behaviour does not mean that all the films are classical semiconductors. Actually, for $x = 0.05$, the ratio of the resistivity at 5 and 300 K ($\rho(5)/\rho(300)$) is about 1.3, while it is largely higher than 10 for the other curves. This 1.3 value is not expected for a classical semiconductor presenting a thermally activated transport mechanism. The carrier density in this film ($1.3 \times 10^{19} \ \text{cm}^3$) being higher than the critical Mott density for ZnO, i.e. from $5 \times 10^{18}$ to $1 \times 10^{19} \ \text{cm}^3$ following the reports [25,26], this film is degenerated, and a metallic behaviour should be observed in the $\rho(T)$ curve. However, the 5% Fe doping induces a structural disorder in the films, and the defects act as scattering centres for the carriers. This leads to an increase of the resistivity. The negative TCR in Fig. 6 for the 5% Fe doped film can thus be observed when the Fermi wavelength $\lambda_f (2\pi/(3\pi^2 n^{1/3})$ becomes comparable to the electronic mean free path $L (h/\rho n e^2 \lambda_f)$ due to large scattering of the carriers [27-28]. These two values are of the same order for this film, 3.2 and 1.25 nm respectively. In these conditions, the negative TCR and small increase in resistivity with decreasing temperature is due to the quantum corrections to conductivity [27]. Such a behaviour has already been observed in disordered pure or doped ZnO and other oxide films [28,29].

The other $\rho(T)$ curves in Fig. 6 present a more classical semiconductor behaviour, with a negative TCR leading to a large increase of resistivity with decreasing temperatures. This is mainly due to a lower carrier density in the films (see Fig. 5), excluding thus the formation of degenerate semiconductors. Such curves are generally explained in the high temperature part, by a thermally activated transport mechanism described by the following equation:

$$\rho(T) = \rho_0 \exp(E_0 / kT)$$

$E_0$ being the activation energy for the transport. Then with decreasing temperature, the thermal energy is no longer sufficient to move electrons in the conduction band, and localisation of the carriers occurs. The thermally activated regime is then followed at lower temperatures by the variable range hopping mechanism (VRH) proposed by Mott in which the resistivity is described by the following relationship:

$$\rho(T) = \rho_{M0} \exp(T_{M0} / T)^{1/4}$$

The charge transport occurs by hopping from a localized site to another site in the vicinity of the Fermi level [30]. A development of this model has been proposed by Efros-Shklovskii.
(ES) [31], which takes into account the Coulomb interaction between localized carriers. This leads to the following temperature variation for the resistivity:

$$\rho(T) = \rho_{ES0} \exp\left(\frac{T_{ES0}}{T}\right)^{1/2}$$

In these relationships, $T_{M0}$ and $T_{ES0}$ are the characteristic temperature of each VRH model.

Fig. 7a and 7b present the curves resulting of this analysis for three typical cases. For $x = 0.85$, the film is solely composed of the spinel phase, and the Arrhenius plot $\ln \rho = f(1/T)$ in Fig. 7a shows a linear part between RT and about 120 K. The activation energy $E_0$ deduced from the slope is equal to 68 meV, a value close to those reported for zinc ferrite films [13, 20]. For $T < 120$ K, the Arrhenius plot is no longer linear and the Mott VRH approach is shown in Fig. 7b, with the $\ln \rho = f\left(\frac{1}{T^{1/4}}\right)$ plot. A linear variation is observed for $120$ K $< T < 80$ K, leading to a $T_{M0}$ value equal to $5.55 \times 10^7$ K, similar to those previously reported [13]. The inset in Fig. 7b presents the plot ($\ln \rho = f\left(\frac{1}{T^{1/2}}\right)$) corresponding to the ES model, and shows a linear variation between 80 and 40 K, indicating that a crossover from the Mott VRH to the ES VRH model is observed in the pure spinel film, as it has been observed and modelled in the case of other oxide films [32,33].

Table I shows the values of $E_0$ and $T_{M0}$ obtained for the various Zn$_{1-x}$Fe$_x$O films. For the Zn$_{0.35}$Fe$_{0.65}$O composition, the $E_0$ and $T_{M0}$ values are rather close to those of the pure spinel ($x = 0.85$), in agreement with Fig. 6, which shows a very similar behaviour for the $\rho(T)$ curves of these two samples. This means that some kind of percolation occurs in the Zn$_{0.35}$Fe$_{0.65}$O films, with a current passing through the zinc ferrite phase and avoiding the higher resistive wurtzite phase. The $\rho(T)$ curves of the two other films of the mixed region (Zn$_{0.65}$Fe$_{0.35}$O and Zn$_{0.5}$Fe$_{0.5}$O) have been analysed by the same approach, however the physical meaning of the values ($E_0$ and $T_{M0}$) are less clear. Actually, both wurtzite and spinel phases are present and both contribute to the electronic transport but their respective contribution to the resistivity as are not known, and cannot be straightforward extracted from the $E_0$ and $T_{M0}$ values given in Table I.

Finally, Table I shows that an $E_0$ value is not given for the Zn$_{0.75}$Fe$_{0.25}$O film. In fact a very good fit was obtained with the Mott VRH model from RT down to 155 K (Fig. 7b), representing a far better fit than that obtained with the thermally activated transport mechanism in Fig. 7a ($E_0 = 160$ meV, from 300 to 250 K). This means that this film is at RT in the strong localization regime leading to the hopping transport mechanism. This has to be related to the very important disorder [25,29] in this film, due to the large incorporation of Fe (25%) in the ZnO wurtzite network. Below 155 K, the resistivity of this film varied with the Efros-Shklovskii (ES) model, as shown by the linear variation observed in Fig. 7b. In this case, a crossover from Mott VRH to ES VRH is also present.

**Optical Properties**

Fig. 8a and 8b show the optical transmittance spectra in the UV-visible and near infrared domain (300 to 3200 nm) for Zn$_{1-x}$Fe$_x$O films with different Fe concentrations. For the lowest x values ($x \leq 0.35$), the curves in Fig. 8a are similar to that recorded on a pure ZnO films grown under the same conditions. Actually these curves present a high transmittance (> 85%) in the visible and near infrared wavelength domain (500 – 3200 nm). On the contrary, for Fe concentrations corresponding to mixed (Zn$_{0.35}$Fe$_{0.65}$O) or spinel (Zn$_{0.15}$Fe$_{0.85}$O) films, a large decrease in the optical transmittance in the 500 – 3200 nm domain is clearly observed in Fig. 8b.
The optical band gap energy $E_g$ of such oxide films was classically deduced from the absorption coefficient $\alpha$ using the Tauc relationship [34]:

$$\alpha h\nu = A (h\nu - E_g)^q$$

with $\alpha$ the optical absorption, $h\nu$ the incident photon energy, $A$ is a constant and $q$ characterizes the optical absorption process with a value equal to 2 or $\frac{1}{2}$ for allowed indirect and direct electronic transitions respectively [34]. It follows that in a plot of $(\alpha h\nu)^{1/q} = f(h\nu)$, the extrapolation to $\alpha = 0$ of linear portion of $(\alpha h\nu)^2$ and $(\alpha h\nu)^{1/2}$ plot would lead to the determination of the direct and indirect band gap value respectively [34].

In inset of Fig. 8a, the Tauc plot corresponding to the wurtzite domain ($x \leq 0.35$) leads to the determination of the direct band gap $E_g$ values, which are given in Table 1. For undoped ZnO films ($x = 0$) the optical bandgap depends upon the growth methods and conditions and is generally found around $3.3 - 3.4$ eV. The values reported in Table 1 lay in this domain and show that for Fe concentrations in the 25 to 35% range, the $E_g$ value ($3.37 - 3.38$ eV) is higher than that obtained for the 5% Fe concentration ($3.31$ eV), while generally the band gap value of Fe doped ZnO films is found to decrease with increasing Fe concentrations. It has to be noticed that the $\text{Zn}_{0.95}\text{Fe}_{0.05}\text{O}$ film presents a high carrier density ($1.3 \times 10^{19}$ cm$^{-3}$) which makes it degenerated, i.e. a band gap renormalization has occurred leading to the band gap shrinking which can explain the low $E_g$ value for the $\text{Zn}_{0.95}\text{Fe}_{0.05}\text{O}$ film.

Fig. 9a and 9b show the $(\alpha h\nu)^2$ Tauc plot for the mixed and spinel domains respectively. For the mixed domain ($x = 0.65$) a direct band gap value (3.17 eV) was deduced (Fig. 9a) which could be related to the presence of the Fe doped ZnO wurtzite phase, as this value is relatively close to the ZnO band gap. In insert of fig. 9a, the $(\alpha h\nu)^{1/2}$ Tauc plot leads to a value of 1.67 eV for the indirect band gap which has to be related to the zinc ferrite spinel phase. Actually indirect band gap values in the 1.5 to 1.7 eV have been reported for this phase [35-37]. In Fig. 9b, the direct band gap value (2.79 eV) is close to the value reported for the zinc ferrite spinel phase [35-37] in agreement with XRD results showing solely the presence of this phase. Moreover, a value equal to 1.54 eV is obtained from the $(\alpha h\nu)^{1/2}$ Tauc plot (indirect band gap) presented in insert in Fig. 9b. The rather large scattering of the direct and indirect bandgap values may be related to the differences in zinc ferrite composition and to the different growth conditions with respect to the previous reports [35-37].

Magnetic properties

Magnetic measurements were carried out at 300 K on each type of sample applying the magnetic field $\mu_0 H$ in the plane of the film. The magnetization evolution as a function of $H$ is shown in Fig. 10a and 10b. For $x = 0.05$, a very faint magnetic signal is observed at the detection limit of the apparatus (Fig. 10a). From $x = 0.05$ up to $x = 0.35$, the magnetic signal gets more intense, and the magnetization value at saturation seems to increase linearly with $x$. However, the saturation magnetization value reached at $x = 0.35$ is only 11 kA m$^{-1}$. Assuming 0.35 Fe atom per ZnO formula unit, this gives an average magnetic moment per Fe atom equal to 0.08 $\mu_B$, where $\mu_B$ is the Bohr magneton. As we know from the X-ray results that a secondary phase exists at $x = 0.35$ with a composition close to FeO which is antiferromagnetic, this magnetic moment per Fe atom may be underestimated. In any case, its value keeps very low when compared to the known magnetic moments carried by Fe$^{2+}$ or Fe$^{3+}$ cations in oxides, which are equal to 4 and 5 $\mu_B$, respectively. Hence, whatever the exact proportion of Fe$^{2+}$ and/or Fe$^{3+}$ cations in our films, their magnetic moments do not couple
ferromagnetically. As a confirmation, no hysteresis is observed; the remanent magnetization \( M_r \), as well as the coercitive field \( H_c \), are equal to zero. As in the case of the Co-doped ZnO films which have been studied for a long time with controversy (for a review, see reference [38]), the ferromagnetism is not observed in the Fe-doped ZnO films providing that the wurtzite phase does not coexist with a ferromagnetic secondary phase (e.g. metallic clusters).

Distinctly, a strong magnetization signal together with a M(H) hysteresis cycle are measured for \( x = 0.65 \) (Fig. 10b). The value at saturation (\( M_s \)) is equal to 216 kAm\(^{-1}\), the \( M_r \) remanent magnetization is 70% of \( M_s \), and the coercitive field \( H_c \) is equal to 11 mT. For a direct comparison with the \( x = 0.35 \) case, under assumption of randomly dispersed Fe atoms in a ZnO matrix, the \( M_s \) value measured for \( x = 0.65 \) would correspond to 0.85 \( \mu_B \) per Fe atom (with respect to 0.08 \( \mu_B \) determined for \( x = 0.35 \)). For \( x = 0.85 \), a M(H) hysteresis cycle is also observed, the saturation magnetization \( M_s \) reaching 384 kAm\(^{-1}\), that is 1.16 \( \mu_B \) per Fe atom. One may notice the coercitive field is the same than for \( x = 0.65 \). For \( 0.65 \leq x \leq 0.85 \), the room temperature ferromagnetic properties must be analyzed in the context of the spinel oxide phase, instead of the wurtzite phase. At \( x = 0.85 \), the spinel structure is solely detected in the X-ray diagram and the Zn\(_{1-x}\)Fe\(_x\)O film consists in a Zn\(_y\)Fe\(_{3-y}\)O\(_4\beta\) spinel oxide, with an oxygen deficient sublattice. In more details, the Zn\(_{0.15}\)Fe\(_{0.85}\)O\(_{1.2}\) film composition derived from the RBS analysis must be understood as Zn\(_{0.45}\)Fe\(_{2.55}\)O\(_{4\beta}\). In the parent magnetite Fe\(_3\)O\(_4\) spinel, the magnetic moment per formula unit is 4 \( \mu_B \) because of the antiferromagnetic coupling between the Fe\(^{3+}\) cations (5 \( \mu_B \)) in the tetrahedral sites and the Fe\(^{2+}\)/Fe\(^{3+}\) (4/5 \( \mu_B \)) cations in the octahedral sites. This leads to 4/3 \( \mu_B \) per Fe atom in a spinel matrix. As the Zn\(^{2+}\) cations substitute Fe\(^{3+}\) in the tetrahedral sites, the magnetic moment \( m_{Fe} \) per Fe atom in Zn\(_y\)Fe\(_{3-y}\)O\(_{4\beta}\) is expected to be equal to \( m_{Fe} = (4+6y-2\beta)/(3-y) \mu_B \). The \( x = 0.85 \) value corresponds to \( y \approx 0.45 \) (and \( \beta = 0.4 \)), for which value the magnetic moment per Fe atom is thus worth “on theory” 2.3 \( \mu_B \). The experimental value of 1.16 \( \mu_B \) is 50% of the ideal value because (i) the Zn fraction in the spinel is herein high enough to disturb the AF coupling between the Fe magnetic moments in the octahedral and the tetrahedral sites, (ii) the measurement is carried out at 300 K (the magnetization is known to decrease with respect to increasing temperature according to the Bloch law), (iii) antiphase boundaries may reduce the film overall magnetization. Nevertheless, the ferromagnetic signal is high and unambiguous. The zinc ferrite Zn\(_y\)Fe\(_{3-y}\)O\(_{4\beta}\) spinel films and their magnetic properties have been recently studied with more details in reference [13]. At \( x = 0.65 \), the ZnO wurtzite and the Zn\(_y\)Fe\(_{3-y}\)O\(_4\) spinel phases coexist (see Fig. 1). The intensity of the spinel peak in the X-ray diagram is about half that at \( x = 0.85 \). As a matter of fact, the magnetic signal for \( x = 0.65 \) is reduced by about two with respect to the signal for \( x = 0.85 \), while the magnetic characteristics of the hysteresis cycle (\( M_r/M_s \) and \( H_c \)) are unchanged. One may reasonably consider the film \( x = 0.65 \) as consisting of a mixture of non-magnetic wurtzite ZnO crystallites and room temperature ferromagnetic spinel Zn\(_{0.45}\)Fe\(_{2.55}\)O\(_4\) crystallites in almost equal proportion. Such a repartition of the wurtzite and spinel phases can explain the percolation phenomenon through the spinel phase which has been deduced from the transport properties measurements (Fig. 6 and 7) in the \( x = 0.65 \) film.

Discussion

Depending upon the Fe concentration, Fe-diluted ZnO wurtzite and/or Zn-diluted Fe\(_3\)O\(_4\) spinel phases were found in the Zn\(_{1-x}\)Fe\(_x\)O films. Actually, for \( x \leq 0.35 \), epitaxial films with a wurtzite structure are formed, while for \( x > 0.65 \), spinel epitaxial films are observed. In the intermediate region (0.35 < \( x < 0.65 \)) the films are constituted by both wurtzite and spinel phases.
The formation of such a mixture of phases is not so trivial as the chemical reactions leading to wurtzite ZnO and pure Fe spinel (Fe$_3$O$_4$) or Fe-Zn spinel (ZnFe$_2$O$_4$) is linked to oxygen pressure and to the relative stability of each phase. For a given oxygen pressure the free energy of the oxide formation from one mole of O$_2$ is lower for ZnO (-640 kJ) than for Fe$_3$O$_4$ (-507 kJ) or ZnFe$_2$O$_4$ (-532 kJ) [39], meaning that the crystallisation of the ZnO phase will be the driving force during the growth of a Zn$_{1-x}$Fe$_x$O based film. It comes that the ZnO phase may grow at the expense of the remaining oxide film which will become more and more oxygen deficient, i.e. Fe$^{2+}$-based oxide phase may therefore be preferentially formed after ZnO. This means that FeO (Fe$^{2+}$ valence state) would be first preferentially synthesized with respect to Fe$_3$O$_4$ (mixed valence states Fe$^{2+}$ and Fe$^{3+}$ phase) or ZnFe$_2$O$_4$ (pure Fe$^{3+}$ valence state).

Depending on the growth conditions, the phase separation can be partial (leading to the formation of a suboxide) or complete (metallic clusters can be formed in a stoichiometric oxide matrix) as previously observed [15-17]. In our work, diffraction peaks associated to Fe metal clusters were never observed. It means that a complete phase separation does not occur in our experimental growth conditions. This could be due first, to the residual pressure which is not sufficiently low to induce a sufficient oxygen deficiency in the film, and secondly, to the fact that iron oxide phases with low energy formation exist. Actually Fe clusters in a ZnO matrix has been solely obtained by Fe ion implantation followed by an annealing treatment [5,10]. However, a pre-annealing of the ZnO crystal under vacuum (i.e. under reducing conditions) before Fe implantation hindered the formation of Fe clusters, and preferentially led to the formation of the zinc ferrite phase [5,40]. The defects induced in the ZnO crystal by the reducing annealing (oxygen vacancies) seem to favor the formation of the zinc ferrite phase at the expense of the Fe metallic clusters [5,40]. In our work, comparable conditions are present in the oxygen deficient Zn$_{1-x}$Fe$_x$O$_{1.5}$ films, and the formation of the zinc ferrite phase occurs instead of the synthesis of Fe clusters in the ZnO matrix. It has to be noticed that while pre-annealed ZnO crystal doped with Fe do not show metallic Fe cluster formation, such a treatment does not prevent Co cluster formation in similar experiments [5]. We have obtained the formation of metallic Co clusters in a ZnO matrix using PLD of highly Co-doped (50 %) ZnO target at 500°C under residual pressure [41].

The physical properties of the Zn$_{1-x}$Fe$_x$O films are directly related to the nature of the phases present as a function of the x value.

$0 < x < 0.35$ : optically transparent films are grown with the ZnO like-structure. However, the resistivity drastically increases with increasing iron content, meaning that such films cannot be used for transparent conductive oxide applications. Moreover, noticeable magnetic properties have not been evidenced in this iron concentration domain, i.e. such Fe-doped ZnO films do not behave as diluted magnetic semiconductors.

$0.65 < x < 1$ : the films crystallize in the spinel phase, and for growth under reducing conditions, they display remarkable ferromagnetic and spin polarized charge transport properties, which have been described in details in a previous report [13], and could lead to interesting applications in spintronics.

In the intermediate region where the wurtzite and spinel phase coexist, the physical properties of the nanocomposite films depend upon the respective fraction of the transparent highly resistive wurtzite phase and of the half metallic ferromagnetic zinc ferrite spinel phase. For increasing x values, both the resistivity and optical transparency decreases. For $x = 0.65$ such nanocomposite films present both a noticeable reduced optical transparency (< 60%) in the visible wavelength domain with respect to the wurtzite-type films, and a reasonably low
resistivity \((5 \times 10^{-2} \, \Omega \text{cm})\), two properties searched for in view of photoelectrochemical water splitting. As a matter of fact, it has been recently shown that Fe\(_3\)O\(_4\)-ZnO nanoparticles on graphene could be a promising candidate for solar hydrogen production [42]. Besides, the existence of two distinct oxide nanocrystalline phases in thin films could induce a low thermal conductivity via the phonon scattering at the interfacial boundaries between the two phases, which coupled with the reasonable electrical conductivity may open the way for good thermoelectric properties [43].

**Conclusion**

The phase diagram of Zn\(_{1-x}\)Fe\(_x\)O films grown by PLD under reducing conditions on sapphire substrates has been investigated in the whole \(0 < x < 1\) range, i.e. from ZnO to Fe\(_3\)O\(_4\). Three domains have been clearly identified. For \(0 < x < 0.3\), the films adopt the ZnO-like structure without noticeable electrical or magnetic properties, except the fact that the Fe incorporation is accompanied by a very steep increase of the resistivity. For \(0.35 \leq x \leq 0.65\), the existence of two distinct crystalline phases (ZnO-like and Fe\(_3\)O\(_4\)-like) induces reasonable optical absorption in the visible wavelength domain while limiting the electrical conductivity. These nanocomposite films may be envisaged as photoanodes in water splitting or alternatively may open the way for thermoelectric applications. For \(x > 0.65\), pure spinel Zn\(_y\)Fe\(_{3-y}\)O\(_4\) films are grown displaying room temperature ferromagnetism and spin polarized charge transport properties.

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**References**


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Figure captions

**Fig. 1**: 0-20 diffraction patterns of films with different Fe concentration in the 2θ range from 30 to 40°.

**Fig. 2**: Values of the lattice parameters of the wurtzite phase (c-axis and a-axis) as a function of the Fe concentration in films grown at 500°C under 5x10⁻⁷ and 10⁻² mbar.

**Fig. 3**: Pole figures recorded for films (a) with x = 0.25 (wurtzite phase), and the (101) reflection (2θ = 36.25°); (b) with x = 0.85 (spinel phase), and the (220) reflection (2θ = 29.8°).

**Fig. 4**: 0-20 diffraction patterns of films (x = 0.5) grown under 5x10⁻⁷ mbar and 10⁻² mbar oxygen pressure.

**Fig. 5**: (a) Resistivity ρ as a function of the Fe concentration for films grown under 5x10⁻⁷ mbar at 500°C; (b) density and mobility of the carriers in the 0 < x < 0.35 concentration range.

**Fig. 6**: Temperature dependant resistivity (ρ) for films with different x values.

**Fig. 7**: (a) variation of Log (ρ) with (1/T) for films with various Fe concentration; (b) variation of Log (ρ) with (1/T¹/⁴) for films with various Fe concentration, in inset variation of of Log (ρ) with (1/T¹/²).

**Fig. 8**: UV-visible-near IR transmittance for (a) films with x ≤ 0.35, the inset shows the corresponding Tauc plot; (b) for films with x ≥ 0.65.

**Fig. 9**: Tauc plot for the direct band gap and the inset shows the tauc plot for indirect bandgap for (a) film with x = 0.65; (b) film with x = 0.85.

**Fig. 10**: M-H curves recorded at 300K for (a) wurtzite type films (x ≤ 0.35); (b) films with spinel and both spinel and wurtzite phases (x ≥ 0.65).
Table I

<table>
<thead>
<tr>
<th>x</th>
<th>E₀ (meV)</th>
<th>Tₘ₀ (K)</th>
<th>direct band gap (eV)</th>
<th>indirect band gap (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>0.05</td>
<td>-</td>
<td>-</td>
<td>3.31</td>
<td>-</td>
</tr>
<tr>
<td>0.25</td>
<td>-</td>
<td>1.34x10⁸</td>
<td>3.37</td>
<td>-</td>
</tr>
<tr>
<td>0.35</td>
<td>191 (300K-200K)</td>
<td>2.5x10⁵ (150K-50K)</td>
<td>3.38</td>
<td>-</td>
</tr>
<tr>
<td>0.5</td>
<td>95 (300K-210K)</td>
<td>1.6x10⁷ (210K-160K)</td>
<td>-</td>
<td>-</td>
</tr>
<tr>
<td>0.65</td>
<td>82 (300K-130K)</td>
<td>4.35x10⁷ (110K-50K)</td>
<td>3.17</td>
<td>1.67</td>
</tr>
<tr>
<td>0.85</td>
<td>68 (300K-120K)</td>
<td>5.55x10⁷ (120K-80K)</td>
<td>2.79</td>
<td>1.54</td>
</tr>
</tbody>
</table>
Fig. 1

Fig. 2
Fig. 3a

Proj Schmidt
2θ = 36.25°
φ = 90°

[210] Zn_{11}Fe_{32}O

[210] Al_{2}O_{3}

Fig. 3b

Proj Schmidt
2θ = 29.8°
φ = 90°

[11-2] Zn_{11}Fe_{32}O

[210] Al_{2}O_{3}
Fig. 4

Fig. 5
Fig. 6

Fig. 7a
Fig. 7b

Fig. 8a
Fig. 9b

Fig. 10a
Fig. 10b
The resistivity of the Zn$_{1-x}$Fe$_x$O thin films drastically depend upon the nature of the phases which are present, i.e. highly resistive Fe-doped ZnO wurtzite and half-metallic Zn-doped Fe$_3$O$_4$ spinel.